

Sheet 1 of 1

Form PTO-1449 (REV. 8-83)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 118039		APPLICATION NO. 10/733,454	
INFORMATION DISCLOSURE STATEMENT  (Use several sheets if necessary)				APPLICANT(S) Shigemi OHTSU et al.			
				FILING DATE December 12, 2003		GROUP 1732	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)							
MDU	1.	Younan Xia et al.; "Soft Lithography"; Annu. Rev. Mater. Sci.; 1998; Vol. 28; pp 153-184					
MDU	2.	B. Michel et al.; "Printing meets lithography: Soft approaches to high-resolution patterning"; IBM J. RES. & DEV.;					
		Vol. 45, No. 5; September 2001; pp 697-719					
EXAMINER				DATE CONSIDERED			
M. Vauger				11/10/06			
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

Date: April 27, 2004